Docket No.: 9369-120US (U01-209418S/SOG)

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of: Naomi OKAMOTO et al.

Application No.: 10/596,757 Confirmation No.: 1205

Filed: June 23, 2006 Art Unit: 1796

For: PROCESS FOR PRODUCING Examiner: Hui H. Chin
POLYBUTADIENE RUBBER AND

RUBBER COMPOSITION

## SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT (IDS)

This is a Supplemental Information Disclosure Statement including a Malaysian Office Action (copy enclosed) dated March 15, 2010, from the Malaysian Patent Office in Malaysian Application No. Pl20062260 and a European Office Action (copy enclosed) dated March 11, 2010, from the European Patent Office in European Application No. 05 820 040.3.

The attached Office Actions are being submitted herewith for the Examiner's consideration and to be placed on record in the present application. It is respectfully requested that this Information Disclosure Statement, and the attached Office Actions, be considered by the Examiner in connection with the above-identified patent amplication.

I hereby certify that each item of information contained in the Information Disclosure Statement was first cited in any communication from a foreign patent office in a counterpart or other foreign application not more than three months prior to the filing of the Information Disclosure Statement.

This Information Disclosure Statement is being submitted after allowance, but before the payment of the issue fee. The Commissioner is hereby authorized to charge the amount of

Application No.: 10/596,757 Docket No.: 9369-120US (U01-209418C/KK)

\$180.00 pursuant to 37 C.F.R. §1.97(d)(2) and 37 C.F.R. §1.17(p) and any deficiencies or credit any overpayments to Deposit Account No. 50-1017.

Dated: April 29, 2010

Respectfully submitted,

Ricardo Unikel

Ricardo Unikel

Registration No.: 52,309 PANITCH SCHWARZE BELISARIO & NADEL LLP

One Commerce Square 2005 Market Street, Suite 2200

Philadelphia, Pennsylvania 19103

(215) 965-1358

(215) 965-1331 (Fax) runikel@panitchlaw.com (E-Mail)

WWS/RU/acw